## Call for papers



## Objective

✓ Widely publish research results on System LSI Design Methodology

## ♦Scope

Areas of interest include, but are not limited to:

- System Design Technology (specification description, performance estimation, testing and verification, high level synthesis, model-based design, HW-SW co-design, design support/environment systems)
- LSI Design Technology (simulation and modeling, layout design, functional/logic synthesis, LSI testing and verification, high-reliable design, low power design, computer-aided design/design environment tools, emerging design technology)
- Design Experience (embedded systems, reconfigurable systems, cyber-physical systems, AI-related technology, IoT/network applications, medical/healthcare applications, security applications, in-car systems, education for system/LSI design)

## About the Transactions

- ✓ Issued twice a year on February and June
- ✓ Submission deadlines are June and October, respectively (Next deadline is October 6, 2021 (hard deadline))
  - \*) From this year, previous December submission deadline (for next August issue) is to be changed to October (for next June issue).
- ✓ All papers are available for free on the Web *http://www.jstage.jst.go.jp/browse/ipsjtsldm*
- ✓ Papers are registered in many databases INSPEC, EI, DBLP, SwetsWise, SciVerse Scopus, CrossRef, Google Scholar, Microsoft Academic Search, JDreamII
- $\checkmark$  Short paper category suitable for preliminary publication
  - A paper with novelty OR useful information is considered for short paper publication.
  - A complete version can be submitted later as a regular paper.
  - <u>A short paper is limited to 2 pages except for acknowledgement and references,</u> and the revised version is within a half page more.
- ✓ Invited papers by world-famous researchers
- 26th issue (February 2021): Youngsoo Shin (KAIST),
  - "Computational Lithography Using Machine Learning Models"
- 25<sup>th</sup> issue (August 2020): Sheldon Tan, Zeyu Sun, Sheriff Sadiqbatcha (University of California at Riverside), *"Interconnect Electromigration Modeling and Analysis for Nanometer ICs: From Physics to Full-Chip"*
- 23rd issue (August 2019): Chaofei Yang, Ximing Qiao, Yiran Chen (Duke University), "Neuromorphic Computing Systems:From CMOS To Emerging Nonvolatile Memory"
- ✓ TSLDM Best Paper Award honors the authors of distinguished paper
- For more details, please visit http://www.sig-sldm.org/tsldm/

